NOTES:

1. SUBSTRATE MATERIAL: **FUSED SILICA**

2. COATING (APPLY ACROSS CLEAR APERTURE)

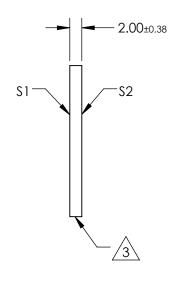
\$1: R(abs)= 30% ±5% @ 350nm, 45° AOI $R(avg) = 30\% \pm 10\% \text{ OVER } 250 - 450 \text{nm}, 45^{\circ} \text{ AOI}$ T(abs)= 70% ±5% @ 350nm, 45° AOI $T(avg) = 70\% \pm 10\% \text{ OVER } 250 - 450 \text{nm}, 45^{\circ} \text{ AOI}$

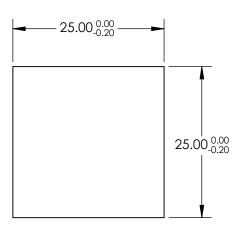
S2: BBAR (R(avg) <1%, R(abs) <2% OVER 250 - 450nm), 45° AOI



EDGES FINE GROUND

4. ROHS COMPLIANT





DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

REV. A	S1	\$2]			Edmund Option	CC®
SHAPE	PLANO	PLANO					US
CLEAR APERTURE	21.25 x 21.25	21.25 x 21.25				25 x 25mm, 30R/70T, UV PLATE BEAMS	PLITTER
SURFACE QUALITY	60-40	60-40	THIRD ANGLE PROJECTION		TITLE	23 X 23HHH, 30K/701, 0 V I EATE BEAMSI EITIEK	
SURFACE FLATNESS	1λ	1λ					CHEET
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED	ALL DIMS IN	mm	DWG NO	48197	SHEET 1 OF 1